| Electronic Patent Application Fee Transmittal | | | | | | | |
|---|----------|---|----------|--------|-------------------------|--|--|
| Application Number: | 10 | 10616097 | | | | | |
| Filing Date: | 08 | 08-Jul-2003 | | | | | |
| Title of Invention: | Mi ba | Multiple-step electrodeposition process for direct copper plating on barrier metals | | | | | |
| First Named Inventor/Applicant Name: | Zł | Zhi-Wen Sun | | | | | |
| Filer: | Ke | Keith Patrick Taboada | | | | | |
| Attorney Docket Number: | A | AMAT/8241/CMP/ECP/RKK | | | | | |
| Filed as Large Entity | | | | | | | |
| Utility Filing Fees | | | | | | | |
| Description | | Fee Code | Quantity | Amount | Sub-Total in USD(\$) | | |
| Basic Filing: | | | | | | | |
| Pages: | | | | | | | |
| Claims: | | | | | | | |
| Miscellaneous-Filing: | | | | | | | |
| Petition: | | | | | | | |
| Patent-Appeals-and-Interference: | | | | | | | |
| Post-Allowance-and-Post-Issuance: | | | | | | | |
| Extension-of-Time: | | | | | | | |
| Extension - 1 month with \$0 paid | | 1251 | 1 | 120 | 120 | | |

| Description | Fee Code | Quantity | Amount | Sub-Total in USD(\$) | | | | |
|-----------------------------------|----------|----------|--------|-------------------------|--|--|--|--|
| Miscellaneous: | | | | | | | | |
| Request for continued examination | 1801 | 1 | 790 | 790 | | | | |
| | Tota | 910 | | | | | | |